

PATENT ASSIGNMENT COVER SHEET

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SUBMISSION TYPE:	NEW ASSIGNMENT
NATURE OF CONVEYANCE:	ASSIGNMENT
CONVEYING PARTY DATA	
Name	Execution Date
THE HONG KONG POLYTECHNIC UNIVERSITY	09/29/2014
RECEIVING PARTY DATA	
Name:	AVALON NANOFIBER LIMITED
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State/Country:	HONG KONG
PROPERTY NUMBERS Total: 1	
Property Type	Number
Application Number:	12775465
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DATE SIGNED:	11/07/2014
Total Attachments: 2	
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ASSIGNMENT OF PATENT APPLICATIONS / PATENTS

The Hong Kong Polytechnic University, a university organized and existing under and by virtue of the laws of Hong Kong, and having an office and place of business at Hung Hom, Kowloon, Hong Kong, hereby assign the entire and exclusive rights and interests in connection with the patent applications / patents listed in the attached Schedule "A" to Avalon Nanofiber Limited, a company duly incorporated under the laws of British Virgin Island and having its registered address at Unit 811-813, IC Development Centre, No. 6 Science Park West Avenue, Hong Kong.

Assignor:

Hong Kong Polytechnic University

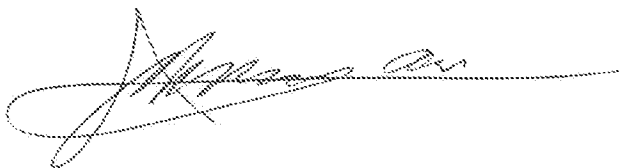


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Johnson Yiu-Nam Lau

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Date: September 29, 2014

Date: September 5, 2014

PATENT

REEL: 034193 FRAME: 0311

Schedule A

Internal Reference no.	Title	First Named Inventor	Country	Filing Date	Patent application no.
IP-343A	Nanofiber filter facemasks and cabin filters	LEUNG Woon-fong, Wallace	USA	4/26/2007	11/740,513
IP-343C	Nanofiber filter facemasks and cabin filters	LEUNG Woon-fong, Wallace	PRC	4/25/2008	200810095933.8
IP-343D	Nanofiber filter facemasks and cabin filters	LEUNG Woon-fong, Wallace	HKSAR	6/9/2009	09105171.1
IP-343E	Nanofiber filter facemasks and cabin filters	LEUNG Woon-fong, Wallace	PRC	4/25/2008	201410128330.9
IP-573B	Multilayer Nanofilber Filter	LEUNG Woon-fong, Wallace	USA	5/6/2010	12/775,465
IP-573D	Multilayer Nanofilber Filter	LEUNG Woon-fong, Wallace	PRC	5/7/2010	201080031111.9
IP-573E	Multilayer Nanofilber Filter	LEUNG Woon-fong, Wallace	GERMANY	5/7/2010	112010001912.6
IP-573F	Multilayer Nanofilber Filter	LEUNG Woon-fong, Wallace	USA (Con)	8/2/2013	13/958,235